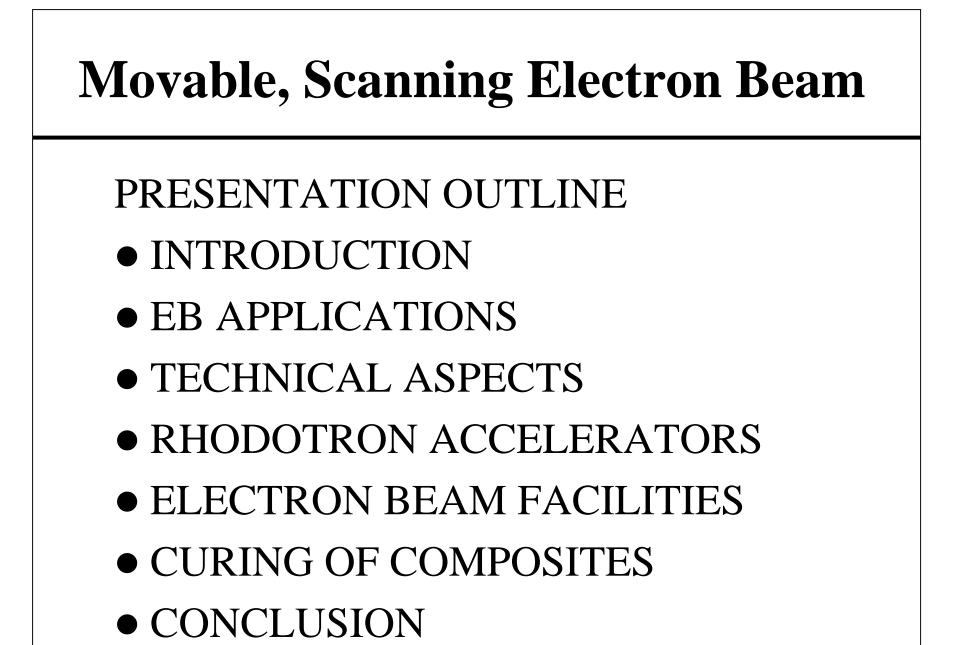
Logistics of a Movable, Scanning Electron Beam

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INTRODUCTION

- Many Electron Beam Facilities
- A Variety of EB Applications
- Most Accelerators Less Than 5 MeV
- New EB Technology Above 5 MeV
- High-Energy Applications Increasing

ELECTRON BEAM APPLICATIONS

- Crosslinking Plastic and Rubber Products
- Sterilizing Single-Use Medical Devices
- Disinfesting and Pasteurizing Foods
- Protecting the Environment
- Modifying Semiconductors and Gemstones
- Curing Composite Structures

TECHNICAL ASPECTS

- Temperature Rise vs Absorbed Dose
- Product Penetration vs Electron Energy
- Area Throughput vs Electron Beam Current
- Mass Throughput vs Electron Beam Power

TEMPERATURE RISE VS ABSORBED DOSE

- $\Delta T = 0.239 \text{ D} / \text{c}$
- ΔT = Temperature Rise in Degrees Celsius
- D=Absorbed Dose in kGy
- c = Thermal Capacity in cal/g degree celsius
- A dose of 10 kGy increases the temperature of water about 2.4 degrees C and plastics about 5 degrees C.

PENETRATION VS ELECTRON ENERGY

- Treatment from One Side
- Equal Entrance and Exit Doses
- E = Electron Energy in MeV
- Z = Thickness x Density in g/sq cm
- Z = 0.37 (E 0.20)
- Z = 3.6 cm of Water at 10 MeV

AREA THROUGHPUT VS BEAM CURRENT

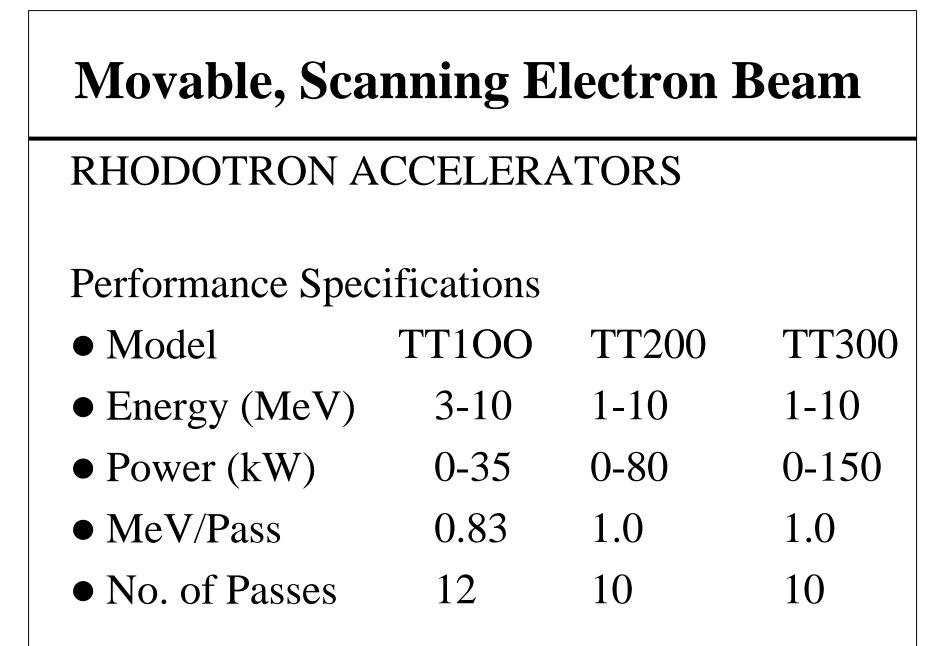
- Unity Rule for High-Energy Electrons
- A beam current of 1 mA delivers a surface dose of about 1 Mrad (10 kGy) to water-like material which moves with an area throughput rate of 1 sq m/min.
- For example: a 10 MeV, 150 kW, 15 mA beam can deliver a surface dose of about 15 Mrad (150 kGy) with an area throughput rate of 1 sq m/min.

MASS THROUGHPUT VS BEAM POWER

- Unity Rule for High-Energy Electrons
- An absorbed beam power of 1 kW delivers an average dose of 1 kGy (0.1 Mrad) to material which moves with a mass throughput rate of 1 kg/see.
- The absorbed beam power is usually in the range of 25% to 50% of the incident beam power. This factor depends on the configuration of the material.

RHODOTRON ACCELERATORS

- Operating Concepts
- Photographs
- Performance Specifications
- Special Features



RHODOTRON ACCELERATORS

Special Features

- High Electrical Efficiency
- Wide Temperature Range
- Short Start-up and Restart Cycles
- Convenient Programmable Logic Controls
- Versatile Beam Transport and Scanning Systems ION BEAM APPLICATIONS

ELECTRON BEAM FACILITIES

- Accelerators can be oriented in any direction.
- Beam direction is usually horizontal or vertical.
- Beam direction can be changed with magnets.
- High-energy EB facilities need thick shielding walls.
- Entrance can be through labyrinths or heavy doors.
- Ventilation is needed to remove ozone gas.

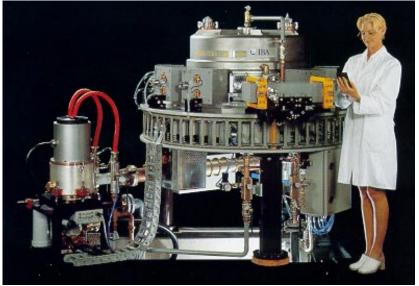
CURING OF COMPOSITE STRUCTURES

Rhodotron Capabilities

- Divergent Beam Scanning
- Parallel Beam Scanning
- Offset Beam Scanning
- Variable Scanning Direction
- Moving Accelerator Platform

Movable Rhodotron

- The Rhodotron can be mounted on a movable platform.
- Platform should hold the following Rhodotron elements in a fixed "relative" position.
 - Rhodotron cavity
 - Scan horn
 - Tetrode assembly
- Tetrode assembly can be relocated.



ION BEAM APPLICATIONS

Movable Rhodotron - Range

• RF signal line

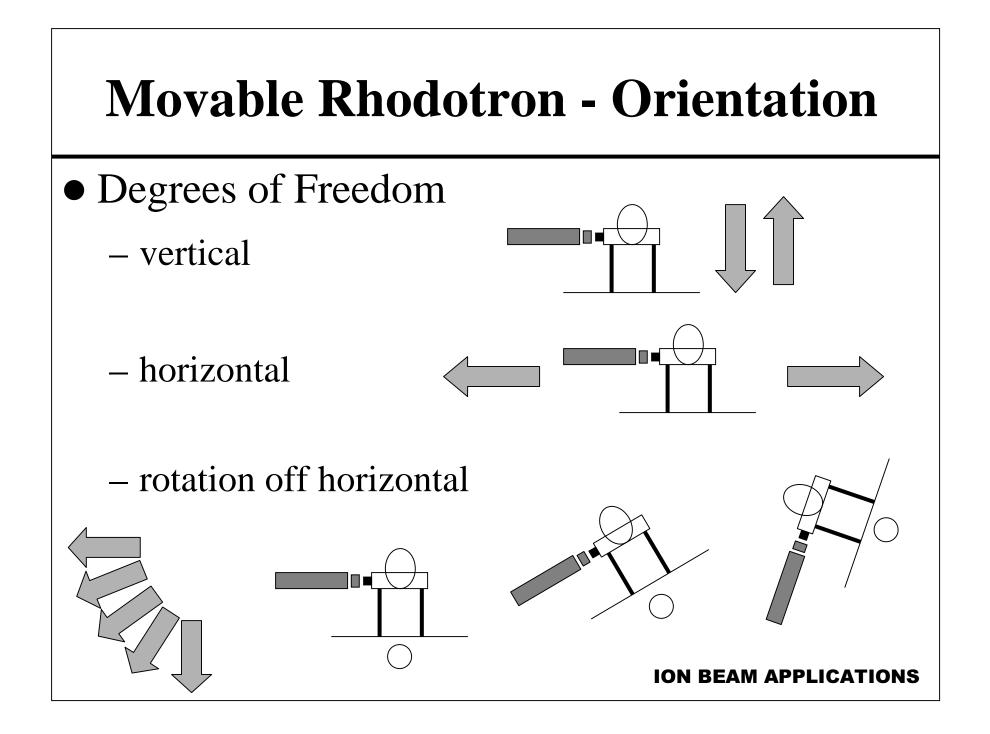
- unrestricted distance from main PS and controls.
- estimated 25% per 100 m power loss in the RF coax signal line to tetrode is easily compensated.
- signal line bending radius of 1 meter.
- rotating coupler at interface of signal line and platform.

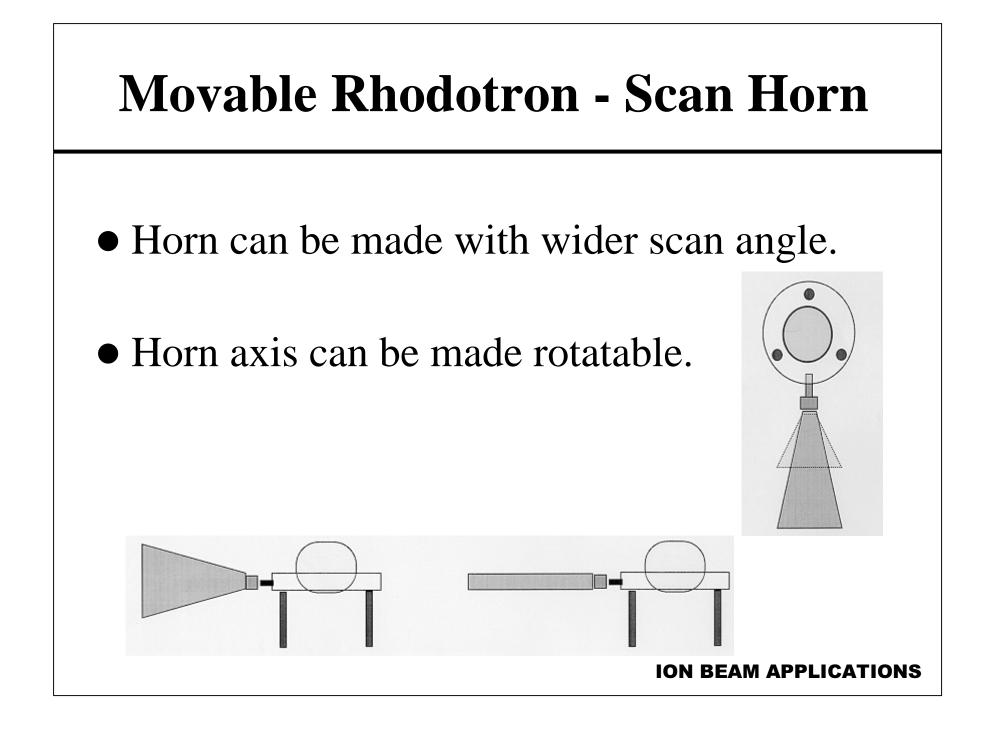
• Cooling lines

– limited distance to reservoir and heat exchanger or mount them on the platform. **ION BEAM APPLICATIONS**

Movable Rhodotron - Shielding

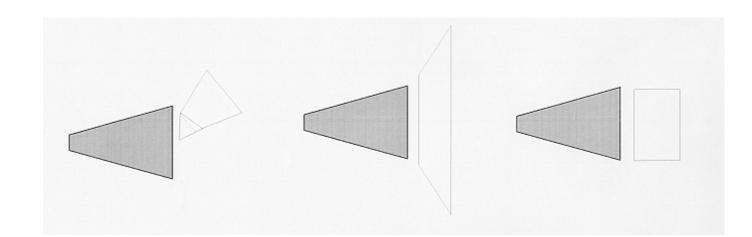
- Rhodotron should be housed in a metallic box.
 - positive air pressure within box to protect against ozone.
 - metallic, to shield against the influence of the earth's magnetic field in different orientations.
 - metallic, to act as an RF shield, if located near an airfield.
- X-Ray shielding of Rhodotron is not necessary.
 - enhanced inspection and maintenance program for vulnerable components.





Movable Rhodotron - Scanning

• Scan offset, divergence, and sweep functions can be used in creative combinations.



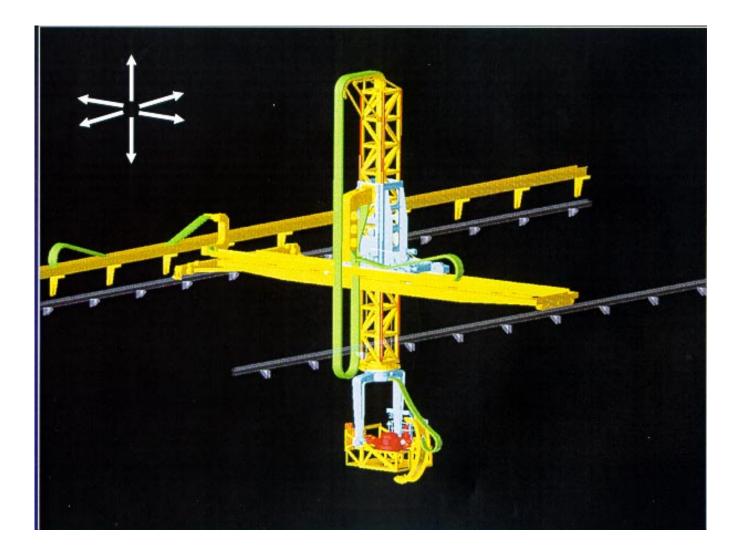
Parallel beam

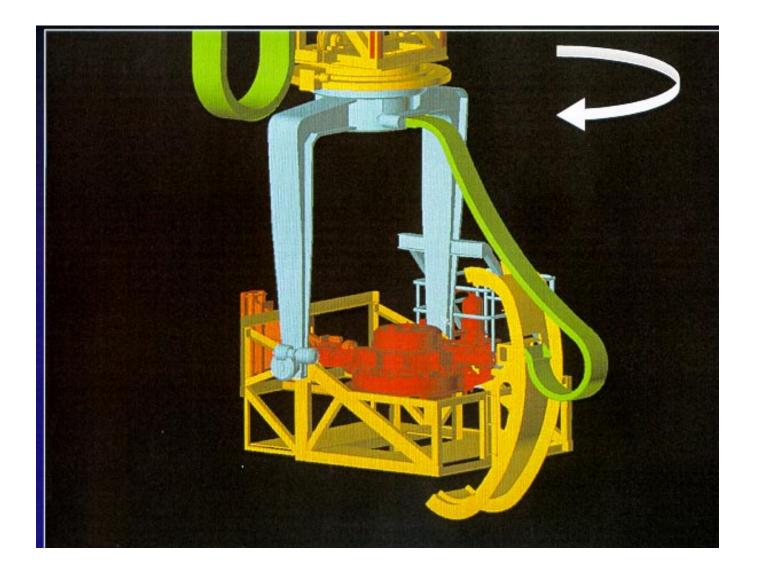
Parallel beam magnets reversed Parrallel beam magnets reversed, with scan offset and modified sweep

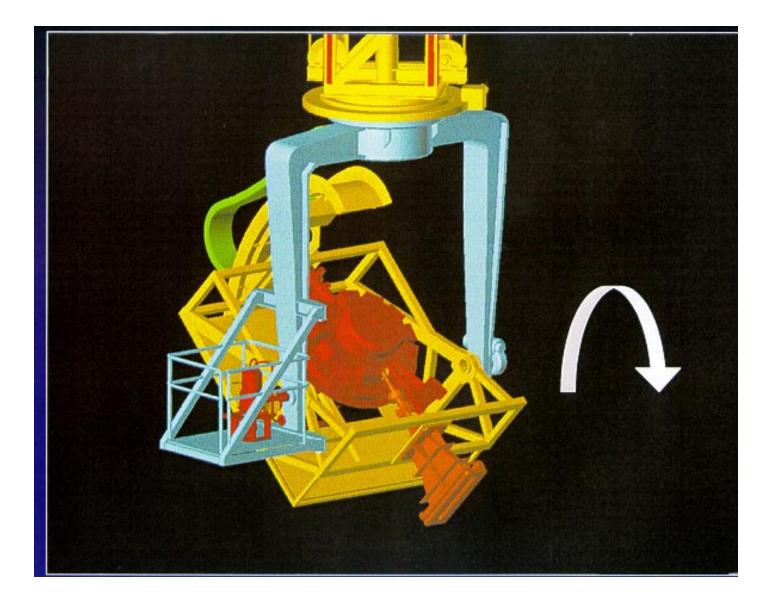
CONCLUSION

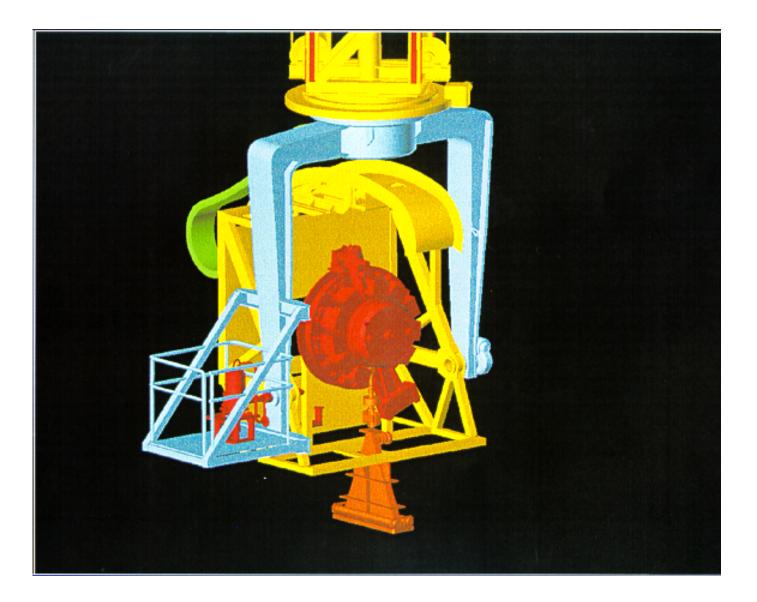
Impact of High-Power, High-Energy Accelerators

- Greater Variety of Applications
- Especially Suitable for Curing Composites
- Treatment of Thicker, More Complex Products
- More Uniform Dose Distributions
- Shorter Treatment Times



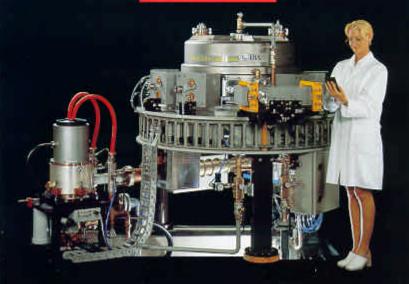






RHODOTRON® TT 100

10 MeV / 35 kW



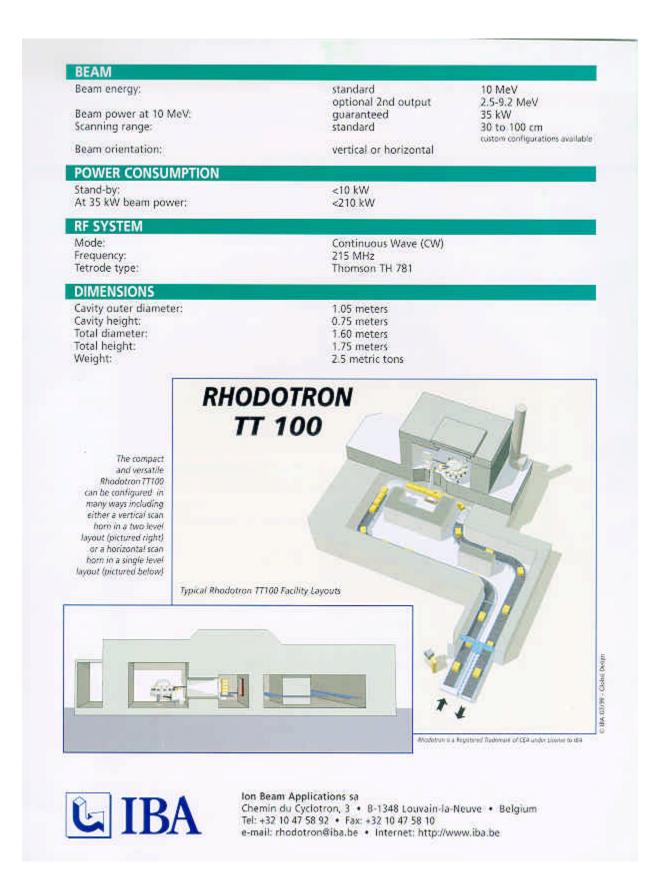
Key Technical Features

- · Up to 10 MeV Electron Beam Energy.
- · 10 to 35 kW Beam Power
- Advanced Scanning Options (parallel scan, scan offset)
- Exceptional Parameter Control (energy, current, scan width)
- State-of-the-Art Control System
- High Electrical Efficiency
- Simple and Robust Design

User Benefits

- * Deep product penetration
- Lowest unit costs for medical device sterilization
- Highest throughput, improved max/min ratios, less ozone production
- Precise, flexible, even and highly reproducible product exposures
- Easy to validate, operate, maintain, and troubleshoot
- . Low operating cost
- Proven commercial reliability, low maintenance requirements





RHODOTRON® TT 200

10 MeV / 80 kW



Key Technical Features

- · Up to 10 MeV Electron Beam Energy
- · Up to 80 kW Beam Power
- Advanced Scanning Options (parallel scan, scan offset)
- Exceptional Parameter Control (energy, current, scan width)
- State-of-the-Art Control System
- High Electrical Efficiency
- · Simple and Robust Design

User Benefits

- Deep product penetration
- Highest throughput and lowest unit processing cost
- Highest throughput, improved max/min ratios, less ozone production
- Precise, flexible, even and highly reproducible product exposures
- Easy to validate, operate, maintain, and troubleshoot
- Low operating cost
- Proven commercial reliability, low maintenance requirements



BEAM	
Beam energy:	standard 10 MeV optional 2nd output 1-9 MeV
Beam power at 10 MeV:	guaranteed 80 kW upgradoble to a TT300
Scanning range:	standard 30 to 100 cm custom configurations avail
Beam orientation:	vertical or horizontal
POWER CONSUMPTION	
Stand-by: At 80 kW beam power:	<15 kW <260 kW
RF SYSTEM	
Mode: Frequency: Fetrode type:	Continuous Wave (CW) 107.5 MHz Thomson TH 681
DIMENSIONS	
Cavity outer diameter: Cavity height: Fotal diameter: Fotal height: Weight:	2.0 meters 1.8 meters 3.0 meters 2.4 meters 11 metric tons
RHODOTRON	
TT 200	



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RHODOTRON® TT 300



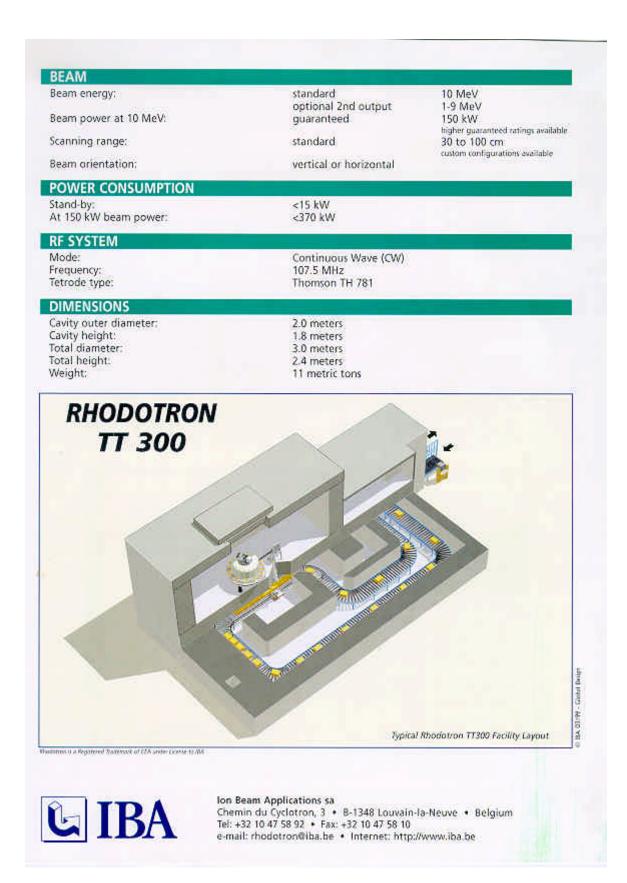
Key Technical Features

- . Up to 10 MeV Electron Beam Energy
- · Up to 150 kW Beam Power.
- Advanced Scanning Options (parallel scan, scan offset)
- Exceptional Parameter Control (energy, current, scan width)
- State-of-the-Art Control System
- · High Electrical Efficiency
- · Simple and Robust Design

User Benefits

- Deep product penetration
- Highest throughput and lowest unit processing cost
- Highest throughput, improved max/min ratios, less ozone production
- Precise, flexible, even and highly reproducible product exposures
- Easy to validate, operate, maintain, and troubleshoot
- · Low operating cost
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* RHODOTRON®

 Coaxial cavity, made of rolled, shaped and welded plates of steel, electrochemically copper-plated

2 RF amplifier

 Cooling system composed of a water judget placed on the inner conductor and end flanges, and of discrete water channels on the outer diameter

4. Sepporting ring

3. Deficiting magnets

Vacuum system
Electron gon

8.10 MeV beam exit

Operating Principle

The Rhodotron repetitively accelerates electrons across a coaxial cavity. The electrons undergo a first acceleration when fired from an external electron gun through openings in the outer cavity towards the inner conductor. As they emerge on the other side of the inner conductor, the natial electric field is reversed, giving them a second acceleration. The beam leaves the cavity, then is bent by a small external magnet, sending the electrons back towards the inner conductor. The rose-shaped pattern described by the acceleration paths gives rise to the name Rhodotron : "modos" in Greek means rose.